

Field Effect Transistors Based Terahertz Detectors History, State of the Art and Future Directions

W.Knap

*International Research Agenda CENTERA, Institute of High Pressure Physics, Polish Academy of
Sciences, 01-142 Warsaw, POLAND*

&

Laboratoire Charles Coulomb University of Montpellier and CNRS, 34980 Montpellier, FRANCE

In the beginning of 90-ties Dyakonov and Shur proposed field effect transistors (FETs) as potential candidates for THz detectors and emitters. In their pioneering works the operation principle has been explained using physical models of plasma-waves propagating (or overdamped) in the channel of the transistors- for review see references [1,2]. Later some specific cases (room temperature overdamped plasma oscillations) has also been described as a distributed self-mixing resistive mixer [3,4] and by a lumped element approach [5]. A complete analytical expression valid in all regions of operation of the FET, including sub-threshold, linear and saturation as well as the loading effect has been proposed in references [6,7]. The theoretical predictions have been confirmed by many experimental results and the matrixes of FETs detectors were reported-for review see reference [8]. The real interest in FET based THz detection and imaging was triggered by a breakthrough discovery that standard Si-MOSFET transistors, in spite their low carrier mobility, can be very efficient detectors [9,10]. Later it has been shown that wide band – up to 4THz single pixel and focal plane arrays operating at sub-THz atmospheric windows can be achieved in Si -Technology [11,12]. Wireless communication applications with Si-CMOS based THz receivers operating at sub-THz bands have been also demonstrated [13].

We present an overview of results concerning THz detection related to plasma nonlinearities in nanometer field effect transistor. The subjects were selected in a way to show physics related limitations and advantages rather than purely technological or engineering improvements of FETs Terahertz detectors. We address the basic physics related problems like temperature dependence of the response [14], helicity sensitive detection [15] and nonlinear/saturation response at high incident power [16]. We present also the first results on new THz detectors based on GaN/AlGaIn edge gate transistors and Si junction-less FETs [17,18] showing that the signal-versus gate voltage has unusual behavior and the results cannot be interpreted using standard models. A new theoretical approach is presented. All the recent results will be discussed in view of the physical and technical limitations of FET THz detectors and their application for quality control and postal security and nondestructive quality control linear scanners [19].

Finally, we will discuss possible future direction for FET-THz detectors improvements and applications.

- [1] W. Knap and M. Dyakonov et al in *Handbook of Terahertz Technology edited by D. Saeedkia (Woodhead Publishing, Canada)*, pp. 121-155 (2013).
- [2] W. Knap, M. Dyakonov, et al "Field Effect Transistors for Terahertz Detection: Physics and First Imaging Applications" *J. Infrared Millim. Terahertz Waves* 30, 1319 (2009)
- [3] Khmyrova and Yu. Seijyou, " Analysis of plasma oscillations in high-electron mobility transistorlike structures: Distributed circuit approach " *Appl. Phys. Lett.* 91, 143515 (2007).
- [4] Lisauskas, U. Pfeiffer, E. O. Ojefors, P. H. Bolivar, D. Glaab, H. G. Roskos, "Rational design of high-responsivity detectors of terahertz radiation based on distributed self-mixing in silicon field-effect transistors", *Journal of Applied Physics*, vol. 105, no. 11, p. 114511 (2009).
- [5] S.Preu et al S. Kim, R. Verma, P. G. Burke, M. S. Sherwin, A. C. Gossard, " An improved model for non-resonant terahertz detection in field-effect transistors ", *Journal of Applied Physics*, vol. 111, 024502 (2012).
- [6] Knap, W., V. Kachorovskii, Y. Deng, S. Rumyantsev, J.Q. Lu, R. Gaska, M.S. Shur, G. Simin, X. Hu, M.A. Khan, C.A. Saylor, and L.C. Brunel, Nonresonant detection of terahertz radiation in field effect transistors. *Journal of Applied Physics*, 91(11): p. 9346-9353 (2002).
- [7] M. Sakowicz, M.B. Lifshits, O.A. Klimenko, F. Schuster, D. Coquillat, F. Teppe, W. Knap, *J. Appl. Phys.* 110, 054512 (2011)
- [8] W. Knap, S. Rumyantsev, M. Vitiello, D. Coquillat, S. Blin, N. Dyakonova, M. Shur, F. Teppe, A. Tredicucci and T. Nagatsuma, *Nanotechnology* 24 (21), 214002-214002 (2013).
- [9] Knap W, Teppe, F, Mezzani, Y, Dyakonova, N, Lusakowski, et al, Plasma wave detection of sub-terahertz and terahertz radiation by silicon field-effect transistors, *Applied Physics Letters*, 85(4): p. 675-677 (2004).
- [10] R. Tauk, F. Teppe, S. Boubanga, D. Coquillat, W. Knap, et al, Plasma wave detection of terahertz radiation by silicon field effects transistors: Responsivity and noise equivalent power" *Appl.Phys.Lett.* 89, 253511 (2006)
- [11] A. Boppel, M. Lisauskas, M. Mundt, D. Seliuta, L. Minkevičius, et al "CMOS Integrated Antenna-Coupled Field-Effect Transistors for the Detection of Radiation From 0.2 to 4.3 THz", *IEEE Transactions on Microwave Theory and Techniques*, vol. 60, No. 12, p.3834 (2012).
- [12] R. Al Hadi et al "A 1 k-Pixel Video Camera for 0.7–1.1 Terahertz Imaging Applications in 65-nm CMOS" *IEEE JOURNAL OF SOLID-STATE CIRCUITS*, VOL. 47, NO. 12, DECEMBER (2012)
- [13] S. Nahar et al "Wide modulation bandwidth terahertz detection in 130 nm CMOS technology " *Eur. Phys. J. Appl. Phys.* 76: 20101 (2016)
- [14] O. A. Klimenko, W. Knap, B. Iniguez, D. Coquillat, Y. A. Mityagin, F. Teppe, N. Dyakonova, H. Videlier, D. But, F. Lime, J. Marczewski and K. Kucharski, *J. Appl. Phys.* 112 (1), 014506-014505 (2012).
- [15] C. Drexler, N. Dyakonova, P. Olbrich, J. Karch, et al *J. Appl. Phys.* 111 (12), 124504-124506 (2012).
- [16] D. B. But, C. Drexler, M. V. Sakhno, N. Dyakonova, et al *J. Appl. Phys.* 115 (16), 164514 (2014).
- [17] G.Cywinski et al "Electrically Controlled Wire-Channel GaN/AlGaIn Transistor for Terahertz Plasma Applications" 112(13):133502 · March 2018.
- [18] J.Marczewski, W.Knap, D. Tomaszewski, M. Zaborowski, P. Zagrajek "Silicon junction less FETs as room temperature THz detectors" *Journal of Applied Physics* 118(104502) (2015)
- [19] Mail scanner: <http://www.ortech.pl/page/22/research-development>